

polymer claims 17-19 for $m > 0$

(FILE 'HOME' ENTERED AT 15:35:32 ON 09 NOV 2001)

FILE 'REGISTRY' ENTERED AT 15:35:42 ON 09 NOV 2001

L1 1388 S 30674-80-7/CRN
L2 20444 S 108-31-6/CRN
L3 56888 S 80-62-6/CRN
L4 90 S 31645-35-9/CRN
L5 10 S L1 AND L2 AND L3 AND L4
L6 19 S L1 AND L2 AND L3
L7 0 S L6 AND 3/NC
L8 20 S L1 AND L2
L9 0 S L8 AND 2/NC
L10 397 S L1 AND L3
L11 2 S L10 AND 2/NC

CH₃
CO₂Et-NCO
mal. anhydride
methyl methacrylate
9-anthracene meth.

FILE 'CAPLUS, USPATFULL' ENTERED AT 15:39:14 ON 09 NOV 2001

L12 41 S L11

FILE 'REGISTRY' ENTERED AT 15:51:05 ON 09 NOV 2001

L13 3 S L1 AND L4
L14 0 S L13 AND 2/NC

FILE 'CAPLUS' ENTERED AT 15:52:22 ON 09 NOV 2001

L15 1 S L13

FILE 'REGISTRY' ENTERED AT 15:52:52 ON 09 NOV 2001

L16 1 S L1 AND 1/NC

FILE 'USPATFULL' ENTERED AT 15:53:45 ON 09 NOV 2001

L17 10 S L16

FILE 'REGISTRY' ENTERED AT 16:04:10 ON 09 NOV 2001

L18 3 S L1 AND L4
L19 2 S L1 AND L3 AND L4

=> s 119 and 3/nc

589592 3/NC

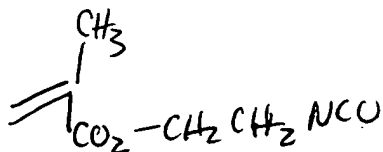
L20 0 L19 AND 3/NC

=>

$4m = 0$

polymer
claims 17-19 for w/momms

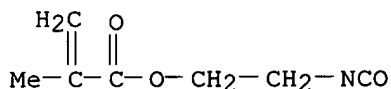
$m > 0$



Zumsteg, Jr., Fredrick C., Wilmington, DE, United States
 PA E. I. Du Pont de Nemours and Company, Wilmington, DE, United States
 (U.S. corporation)
 PI US 5266651 19931130
 AI US 1991-695379 19910503 (7)
 DT Utility
 FS Granted
 EXNAM Primary Examiner: Schofer, Joseph L.; Assistant Examiner: Nagumo, Mark
 LREP Gallegos, R. Thomas
 CLMN Number of Claims: 61
 ECL Exemplary Claim: 1
 DRWN No Drawings
 LN.CNT 1870
 CAS INDEXING IS AVAILABLE FOR THIS PATENT.
 AB Polymer reagents containing reactive functional groups are crosslinked
 by reacting them with compounds (crosslinking agents) which contain
 complimentary functional groups and have large nonlinear polarizability.
 The resulting polymer reagents, after poling, are useful for nonlinear
 optic applications. Also disclosed are the mixture which react to form
 the crosslinked polymer and novel crosslinking agents.
 IT 100042-81-7P, Isocyanatoethylmethacrylate-methyl methacrylate
 copolymer
 (prepn. of, for crosslinked polymer systems for nonlinear optical
 applications)
 RN 100042-81-7 USPATFULL
 CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with methyl
 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

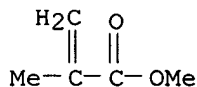
 CM 1

 CRN 30674-80-7
 CMF C7 H9 N O3



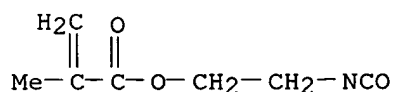
CM 2

 CRN 80-62-6
 CMF C5 H8 O2

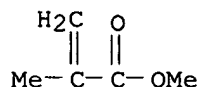


=>

L12 ANSWER 41 OF 41 USPATFULL
 AN 86:3501 USPATFULL
 TI Polymeric sensitizers for photopolymer composition
 IN Dueber, Thomas E., Wilmington, DE, United States
 Monroe, Bruce M., Wilmington, DE, United States
 PA E. I. Du Pont de Nemours and Company, Wilmington, DE, United States
 (U.S. corporation)
 PI US 4565769 19860121
 AI US 1984-673924 19841121 (6)
 DT Utility
 FS Granted
 EXNAM Primary Examiner: Brammer, Jack P.
 CLMN Number of Claims: 11
 ECL Exemplary Claim: 1
 DRWN 3 Drawing Figure(s); 1 Drawing Page(s)
 LN.CNT 818
 CAS INDEXING IS AVAILABLE FOR THIS PATENT.
 AB Photopolymerizable composition consisting essentially of (A) at least one ethylenically unsaturated monomeric compound, (B) at least one 2,4,5-triarylimidazolyl dimer, (C) sensitizing amount of at least one polymeric sensitizer, weight average molecular weight 10,000 to 300,000, which is the reaction product of (1) a reactive photosensitizer and (2) a reactive polymer as defined herein, and (D) optionally an organic polymeric binder. The compositions are useful in photoresists, chemical milling, toning films and printing plates.
 IT 100042-81-7DP, reaction products with dimethylaminophenylhydroxyethoxyphenylmethanone (prepn. of, for polymeric sensitizer for photopolymer compn.)
 RN 100042-81-7 USPATFULL
 CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
 CM 1
 CRN 30674-80-7
 CMF C7 H9 N O3



CM 2
 CRN 80-62-6
 CMF C5 H8 O2



L12 ANSWER 36 OF 41 USPATFULL
 AN 91:62640 USPATFULL
 TI Method of interlaminar grafting of coatings
 IN Halpern, Gregory, Wilson Park Dr., Tarrytown, NY, United States 10591

Campbell, Charles, Highwood Pl., Alpine, NJ, United States 07620
Beavers, Ellington M., 931 Coates Rd., Meadowbrook, PA, United States
19046

Chen, Huk Y., 42-01 Auburndale La., Flushing, NY, United States 11358

PI US 5037677 19910806
AI US 1989-436924 19891107 (7)
DCD 20060131

RLI Continuation of Ser. No. US 1987-34451, filed on 6 Apr 1987 which is a
continuation-in-part of Ser. No. US 1984-643598, filed on 23 Aug 1984,
now patented, Pat. No. US 4801475, issued on 31 Jan 1989

DT Utility
FS Granted

EXNAM Primary Examiner: Kight, III, John; Assistant Examiner:
Hampton-Hightower, P.

LREP Eilberg, William H.

CLMN Number of Claims: 8

ECL Exemplary Claim: 1

DRWN No Drawings

LN.CNT 329

CAS INDEXING IS AVAILABLE FOR THIS PATENT.

AB Interlaminar grafting of coatings, particularly grafting of a lubricious
outer coating upon an anchor coating supported upon glass or plastic,
for example, to provide anti-fogging or lubricating characteristics. The
method is characterized by its ability to anchor permanently the highly
lubricious coating to the glass or plastic.

IT 100042-81-7
(hydrophilic coatings for, isocyanate-crosslinked mucopolysaccharides
as)

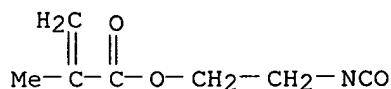
RN 100042-81-7 USPATFULL

CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with methyl
2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 30674-80-7

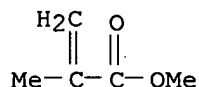
CMF C7 H9 N O3



CM 2

CRN 80-62-6

CMF C5 H8 O2



L12 ANSWER 35 OF 41 USPATFULL

AN 93:100825 USPATFULL

TI Crosslinked poled polymers for nonlinear optic applications and method
of making them

IN Foss, Robert P., Hockessin, DE, United States
Tam, Wilson, Boothwyn, PA, United States

Homop Isocyanate

L43 ANSWER 11 OF 28 CAPLUS COPYRIGHT 2001 ACS
 AN 1997:574793 CAPLUS
 DN 127:264290
 TI Resin composition for water repellency coating.
 IN Kano, Yoshinori
 PA Toyo Ink Mfg. Co., Ltd., Japan
 SO Jpn. Kokai Tokkyo Koho, 6 pp.
 CODEN: JKXXAF
 DT Patent
 LA Japanese
 FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 09221618	A2	19970826	JP 1996-30194	19960219
	JP 2982677	B2	19991129		

AB The title compns. comprise (A) polymers of (a) 20-80% monomers contg. C-C double bond and perfluoroalkyl group, (b) 80-20% of monomers contg. C-C double bond and NCO, epoxy, methylol, N-alkoxymethyl, and/or OH group and (B) polymers of the monomer b. A copolymer of 45% CH₂:CMeCO₂CH₂CH₂(CF₂)₈F and 55% methacryloyloxyethyl isocyanate (I) and a homopolymer of I were used with dibutyltin dilaurate on glass plates.

IT 88007-27-6P

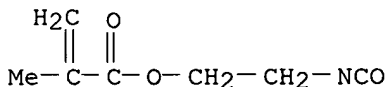
RL: IMF (Industrial manufacture); POF (Polymer in formulation); PRP (Properties); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)

(water-repellent coating compns. with low fluorine content and good adhesion on substrates, acid resistance and hardness)

RN 88007-27-6 CAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, homopolymer (9CI)
 (CA INDEX NAME)

CM 1
 CRN 30674-80-7
 CME C7 H9 N O3



homop monomer

mol. hydr.

11/93

5206651
 Cal 13
 Pivacub

1, 2, 6
 9

5/15/87
 Pats 8 Cal. 9

4663265

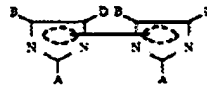
5206651
 5276175

excluded so long as they do not prevent the benefits of the invention from being realized. Other useful additives in the photopolymerizable composition include inhibitors, including photostabilizers, leuco dyes, accelerators such as chain transfer agents, oxygen scavengers, and inert components, e.g., plasticizers, dyes and pigments to increase visibility of the image, fillers, etc.

The ethylenically unsaturated compound (monomer) can be present in the photopolymerizable composition in an amount of 1 to 100 parts by weight, and the organic polymeric binder can be present in an amount of 5 to 57 parts by weight based on the total weight of the monomer and binder. The 2,4,5-triarylimidazoyl dimer photoinitiator can be present in an amount of 0.001 to 20 parts by weight of the combined weight of ethylenically unsaturated compound and binder. The polymeric sensitizer can be present in the photopolymerizable composition in an amount of 0.1 to 10 percent by weight, preferably 5 to 20 percent by weight based on the total dry weight of the composition. The other additives can be present in minor amounts known to those skilled in the art.

The ethylenically unsaturated compounds (A) (photopolymerizable monomers of this invention) have a boiling point above 100° C. at normal atmospheric pressure and are capable of forming a high molecular weight polymer by photoinitiated, addition polymerization. Suitable compounds are disclosed in Cheng U.S. Pat. No. 3,756,827, column 2, line 36 to column 3, line 30, the disclosure of which is incorporated herein by reference. Other useful monomers include ethylenically unsaturated diester polyhydroxy polyethers as described in Chambers U.S. Pat. No. 4,245,031. Examples include the Epocryl® resins sold by Shell Chemical Co. Many of the polymerizable monomers are subject to thermal polymerization, especially when stored for long periods or at elevated temperatures. When such compounds are supplied commercially, it is customary for them to contain a small, but effective, amount of a thermal polymerization inhibitor. These inhibitors may be left in the monomers when the photopolymerizable coating compositions of this invention are prepared. The resulting compositions usually have satisfactory thermal stability. If unusual thermal exposure is anticipated, or if monomers containing little or no thermal polymerization inhibitor are employed, compositions with adequate shelf life can be obtained by incorporating, e.g., up to 0.5 percent, by weight of monomer, of a thermal polymerization inhibitor such as hydroquinone, methylhydroquinone, p-methoxyphenol, etc. Preferred ethylenically unsaturated compounds are methylene glycol diacrylate and trimethylolpropane triacrylate.

Preferably at least one 2,4,5-triarylimidazoyl dimer consisting of two lophine radicals bound together by a single covalent bond (photoinitiator) (B) is present in the photopolymerizable composition. The bimolecules are photolabile in the composition.



wherein A, B and D represent aryl groups which can be the same or different, carbocyclic or heterocyclic, unsubstituted or substituted with substituents that do not interfere with the dissociation of the triarylimidazoyl to the triarylimidazoyl radical or with the oxidation of a leuco dye that may be present and each dotted circle stands for four delocalized electrons (i.e., two conjugated double bonds) which satisfy the valences of the carbon and nitrogen atoms of the imidazoyl ring. The B and D aryl groups can each be substituted with 0-3 substituents and the A aryl groups can be substituted with 0-4 substituents. Useful 2,4,5-triarylimidazoyl dimers are disclosed in Baum and Henry U.S. Pat. No. 3,652,375, column 5, line 44 to column 7, line 16, the disclosure of which is incorporated herein by reference.

The polymeric sensitizers sensitive to ultraviolet or visible radiation (C) useful in the photopolymerizable compositions have been defined broadly above. The polymeric sensitizers are reaction products of a photosensitizer as defined above having a group which is reactive with the reactive polymer or a reactive monomer which is subsequently polymerized to yield a photosensitive polymer. In general, the sensitizer moiety can be covalently bonded to the photosensitive polymer through reactive groups present on one of the alkyl groups attached to the nitrogen atom of the sensitizer moiety or on a substituent present on the aromatic ring which is either ortho or para to the carbonyl group of the sensitizer moiety. The length of the interconnecting alkyl chains can be up to 12 carbon atoms each. The chains are preferably unbranched close to the aromatic ring of the N-atom of the sensitizer so that the planarity of the sensitizer moiety is not altered.

The weight average molecular weight range of the polymeric sensitizer can range from 10,000 to 300,000. The molecular weight can be varied depending on its use. For example, where restricted migration of the polymeric sensitizer is required, the higher molecular weight polymers are preferable.

By way of illustration but not limitation of the invention, useful photosensitive polymers that can be prepared by reaction of a reactive sensitizer moiety with a reactive polymer include:

1. Copolymers of methyl methacrylate and/or methyl acrylate with isooctanoethyl methacrylate.
2. Anhydride containing polymers such as a polymer containing maleic anhydride.
3. Transesterification with poly(methyl acrylate) or esterification of carboxylic acid-containing polymers.

The sensitizer moiety reacting with polymers 1 to 3

poly(Isocya) + -mac / mmA used to make.

Sensitizer Resin -

① yest

344 pm

Ex Matt Good

10/5/01

Reason for All 6151, 481

202-721-8203.

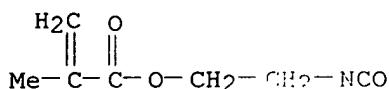
Comments

08

L20 ANSWER 2 OF 2 REGISTRY COPYRIGHT 2001 ACS
 RN 100042-81-7 REGISTRY
 CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with methyl
 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
 OTHER CA INDEX NAMES:
 CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with 2-isocyanatoethyl
 2-methyl-2-propenoate (9CI)
 OTHER NAMES:
 CN 2-Isocyanatoethyl methacrylate-methyl methacrylate copolymer
 CN 2-Methacryloyloxyethylisocyanate-methyl methacrylate copolymer
 CN Isocyanatoethyl methacrylate-methyl methacrylate copolymer
 CN Methacryloyloxyethyl isocyanate-methyl methacrylate copolymer
 DR 179483-85-3, 217467-65-7, 217467-67-9
 MF (C7 H9 N O3 . C5 H8 O2)x
 CI PMS
 PCT Polyacrylic
 SR CA
 LC STN Files: CA, CAPLUS, CHEMLIST, TOXLIT, USPATFULL
 Other Sources: TSCA**
 (**Enter CHEMLIST File for up-to-date regulatory information)

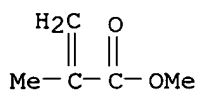
 CM 1

 CRN 30674-80-7
 CMF C7 H9 N O3



CM 2

 CRN 80-62-6
 CMF C5 H8 O2



24 REFERENCES IN FILE CA (1967 TO DATE)
 8 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
 24 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=>

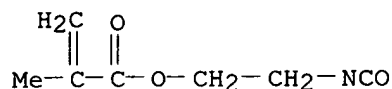
L7 ANSWER 1 OF 1 REGISTRY COPYRIGHT 2001 ACS
RN 88007-27-6 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, homopolymer (9CI)
(CA INDEX NAME)

OTHER NAMES:

CN 2-Isocyanatoethyl methacrylate homopolymer
CN **2-Methacryloyloxyethyl isocyanate homopolymer**
CN Poly(2-isocyanatoethyl methacrylate)
MF (C7 H9 N O3)x
CI PMS
PCT Polyacrylic
LC STN Files: CA, CAPLUS, TOXLIT, USPATFULL

CM 1

CRN 30674-80-7
CMF C7 H9 N O3



28 REFERENCES IN FILE CA (1967 TO DATE)
7 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
28 REFERENCES IN FILE CAPLUS (1967 TO DATE)

Polymers w/ Elect spec.
claim 2

L1 ANSWER 1 OF 10 REGISTRY COPYRIGHT 2001 ACS

RN 222172-97-6 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with diethenylbenzene and methyl 2-methyl-2-propenoate
(9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
diethenylbenzene (9CI)

CN Benzene, diethenyl-, polymer with 2-[[[(9-anthracenylmethoxy)carbonyl]amino]
ethyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI)

MF (C22 H21 N O4 . C10 H10 . C5 H8 O2)x

CI PMS

PCT Polyacrylic, Polystyrene

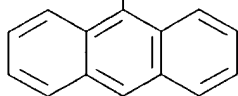
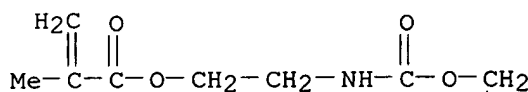
SR CA

LC STN Files: CA, CAPLUS

CM 1

CRN 167859-78-1

CMF C22 H21 N O4



Electel spec. cl 2

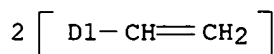


CM 2

CRN 1321-74-0

CMF C10 H10

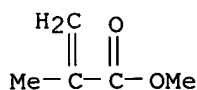
CCI IDS

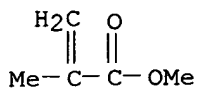


CM 3

CRN 80-62-6

CMF C5 H8 O2





1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

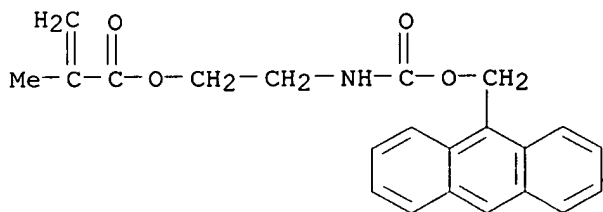
```

L1 ANSWER 2 OF 10  REGISTRY  COPYRIGHT 2001 ACS
RN 222032-33-9  REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-[[ (9-anthracenylmethoxy)carbonyl]amino]ethyl
   1 ester, polymer with methyl 2-methyl-2-propenoate (9CI)  (CA INDEX NAME)
OTHER CA INDEX NAMES:
CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
   2-[[ (9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)
MF (C22 H21 N O4 . C5 H8 O2)x
CI PMS
PCT Polyacrylic
SR CA
LC STN Files:  CA, CAPLUS

```

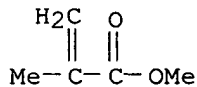
CM 1

CRN 167859-78-1
CMF C22 H21 N O4



CM 2

CRN 80-62-6
CMF C5 H8 O2



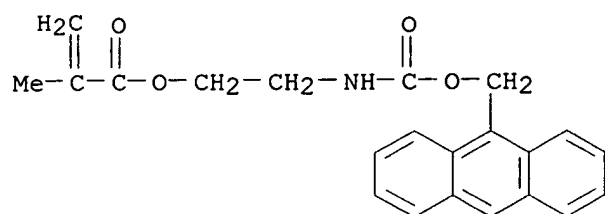
1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

```
L1 ANSWER 3 OF 10  REGISTRY  COPYRIGHT 2001 ACS
RN 222032-31-7  REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-[[ (9-anthracenylmethoxy)carbonyl]amino]ethyl
   ester, polymer with methyl 2-methyl-2-propenoate and 2-propenyl
   2-methyl-2-propenoate (9CI)  (CA INDEX NAME)
OTHER CA INDEX NAMES:
CN 2-Propenoic acid, 2-methyl-, 2-propenyl ester, polymer with
   2-[[ (9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
   methyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
```

2-[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
 2-propenyl 2-methyl-2-propenoate (9CI)
 MF (C22 H21 N O4 . C7 H10 O2 . C5 H8 O2)x
 CI PMS
 PCT Polyacrylic, Polyvinyl
 SR CA
 LC STN Files: CA, CAPLUS

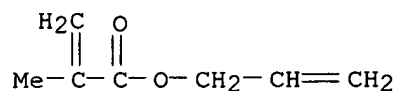
CM 1

CRN 167859-78-1
 CMF C22 H21 N O4



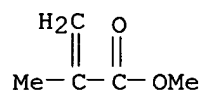
CM 2

CRN 96-05-9
 CMF C7 H10 O2



CM 3

CRN 80-62-6
 CMF C5 H8 O2



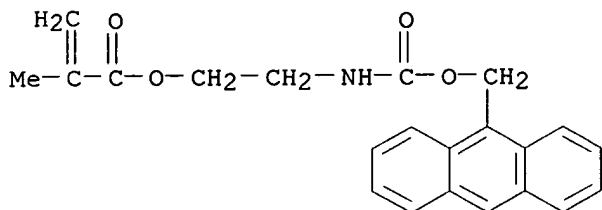
1 REFERENCES IN FILE CA (1967 TO DATE)
 1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 4 OF 10 REGISTRY COPYRIGHT 2001 ACS
 RN 222032-29-3 REGISTRY
 CN 2-Propenoic acid, 2-methyl-, 2-[[(9-anthracenylmethoxy)carbonyl]amino]ethyl
 1 ester, polymer with 2-propenyl 2-methyl-2-propenoate (9CI) (CA INDEX
 NAME)
 OTHER CA INDEX NAMES:
 CN 2-Propenoic acid, 2-methyl-, 2-propenyl ester, polymer with
 2-[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)
 MF (C22 H21 N O4 . C7 H10 O2)x
 CI PMS
 PCT Polyacrylic, Polyvinyl

SR CA
LC STN Files: CA, CAPLUS

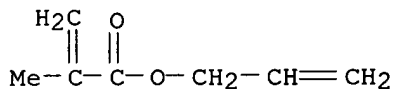
CM 1

CRN 167859-78-1
CMF C22 H21 N O4



CM 2

CRN 96-05-9
CMF C7 H10 O2



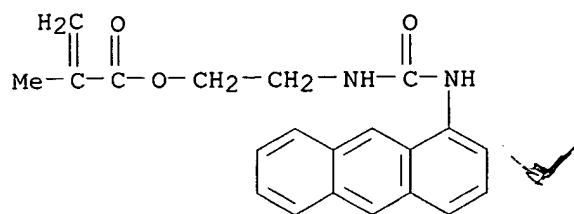
1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 5 OF 10 REGISTRY COPYRIGHT 2001 ACS
RN 222032-28-2 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-[[[(1-anthracenylamino)carbonyl]amino]ethyl ester, polymer with 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate, 2-hydroxyethyl 2-methyl-2-propenoate and oxiranylmethyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
OTHER CA INDEX NAMES:
CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with 2-[[[(1-anthracenylamino)carbonyl]amino]ethyl 2-methyl-2-propenoate, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and oxiranylmethyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 1 ester, polymer with 2-[[[(1-anthracenylamino)carbonyl]amino]ethyl 2-methyl-2-propenoate, 2-hydroxyethyl 2-methyl-2-propenoate and oxiranylmethyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, oxiranylmethyl ester, polymer with 2-[[[(1-anthracenylamino)carbonyl]amino]ethyl 2-methyl-2-propenoate, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and 2-hydroxyethyl 2-methyl-2-propenoate (9CI)
MF (C22 H21 N O4 . C21 H20 N2 O3 . C7 H10 O3 . C6 H10 O3)x
CI PMS
PCT Polyacrylic
SR CA
LC STN Files: CA, CAPLUS

CM 1

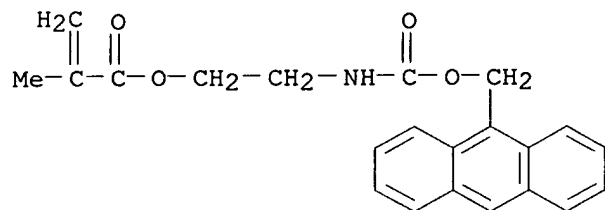
CRN 222032-27-1

CMF C21 H20 N2 O3



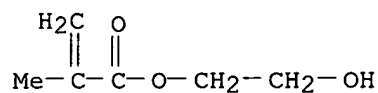
CM 2

CRN 167859-78-1
CMF C22 H21 N O4



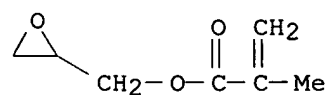
CM 3

CRN 868-77-9
CMF C6 H10 O3



CM 4

CRN 106-91-2
CMF C7 H10 O3



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

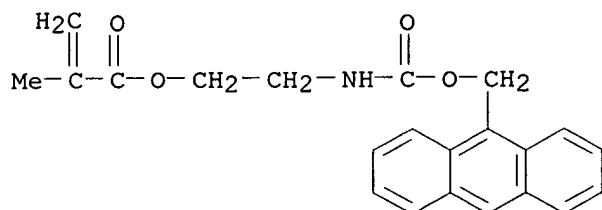
L1 ANSWER 6 OF 10 REGISTRY COPYRIGHT 2001 ACS
RN 222032-26-0 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-[[[9-anthracenylmethoxy)carbonyl]amino]ethyl ester, polymer with 2-hydroxyethyl 2-methyl-2-propenoate and oxiranylmethyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
oxiranylmethyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, oxiranylmethyl ester, polymer with
2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
2-hydroxyethyl 2-methyl-2-propenoate (9CI)
MF (C22 H21 N O4 . C7 H10 O3 . C6 H10 O3)x
CI PMS
PCT Polyacrylic
SR CA
LC STN Files: CA, CAPLUS

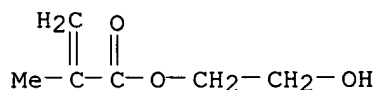
CM 1

CRN 167859-78-1
CMF C22 H21 N O4



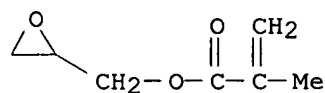
CM 2

CRN 868-77-9
CMF C6 H10 O3



CM 3

CRN 106-91-2
CMF C7 H10 O3



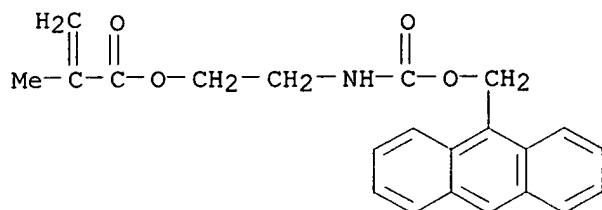
1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 7 OF 10 REGISTRY COPYRIGHT 2001 ACS
RN 222032-25-9 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with oxiranylmethyl 2-methyl-2-propenoate (9CI) (CA
INDEX NAME)
OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, oxiranylmethyl ester, polymer with
 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)
 MF (C22 H21 N O4 . C7 H10 O3)x
 CI PMS
 PCT Polyacrylic
 SR CA
 LC STN Files: CA, CAPLUS

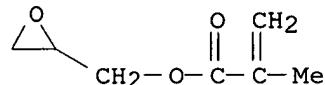
CM 1

CRN 167859-78-1
 CMF C22 H21 N O4



CM 2

CRN 106-91-2
 CMF C7 H10 O3

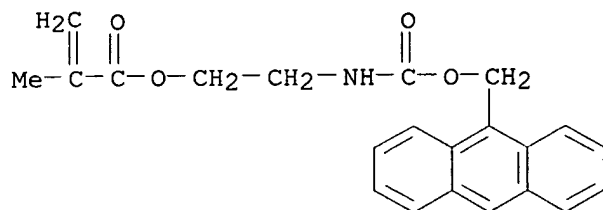


1 REFERENCES IN FILE CA (1967 TO DATE)
 1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 8 OF 10 REGISTRY COPYRIGHT 2001 ACS
 RN 216989-14-9 REGISTRY
 CN 2-Propenoic acid, 2-methyl-, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl
 1 ester, polymer with 2-isocyanatoethyl 2-methyl-2-propenoate and methyl
 2-methyl-2-propenoate (9CI) (CA INDEX NAME)
 OTHER CA INDEX NAMES:
 CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with
 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
 methyl 2-methyl-2-propenoate (9CI)
 CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate and
 2-isocyanatoethyl 2-methyl-2-propenoate (9CI)
 OTHER NAMES:
 CN N-(2-Methacryloyloxyethyl)-9-methylantracene carbamate-methyl
 methacrylate-methacryloxyethyl isocyanate copolymer
 MF (C22 H21 N O4 . C7 H9 N O3 . C5 H8 O2)x
 CI PMS
 PCT Polyacrylic
 SR CA
 LC STN Files: CA, CAPLUS

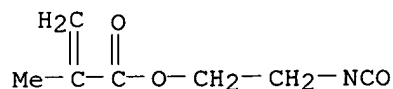
CM 1

CRN 167859-78-1
CMF C22 H21 N O4



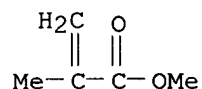
CM 2

CRN 30674-80-7
CMF C7 H9 N O3



CM 3

CRN 80-62-6
CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 9 OF 10 REGISTRY COPYRIGHT 2001 ACS
RN 216989-12-7 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-(acetyloxy)ethyl ester, polymer with
2-[[9-(anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)
(CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-[[9-(anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with 2-(acetyloxy)ethyl 2-methyl-2-propenoate (9CI)

OTHER NAMES:

CN N-(2-Methacryloyloxyethyl)-9-methylanthracene carbamate-2-
methacryloyloxyethyl acetate copolymer

MF (C22 H21 N O4 . C8 H12 O4)x

CI PMS

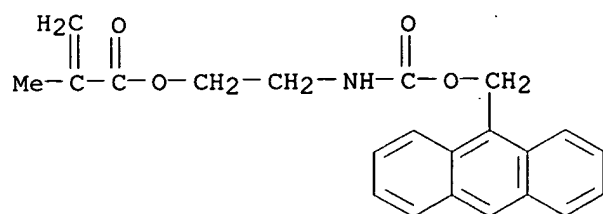
PCT Polyacrylic

SR CA

LC STN Files: CA, CAPLUS

CM 1

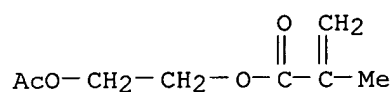
CRN 167859-78-1
CMF C22 H21 N O4



CM 2

CRN 20166-49-8

CMF C8 H12 O4



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 10 OF 10 REGISTRY COPYRIGHT 2001 ACS

RN 167859-79-2 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-[[(9-anthracenylmethoxy) carbonyl] amino] ethyl ester, homopolymer (9CI) (CA INDEX NAME)

MF (C22 H21 N O4)x

CI PMS

PCT Polyacrylic

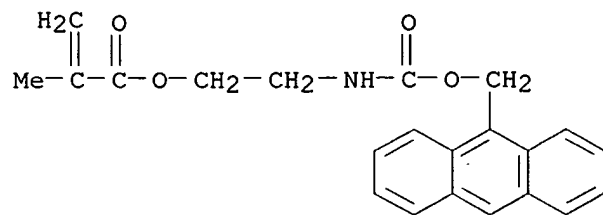
SR CA

LC STN Files: CA, CAPLUS, USPATFULL

CM 1

CRN 167859-78-1

CMF C22 H21 N O4



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=>

Uploading 237c.str

Search sheet spec.
claim 3

L8 STRUCTURE UPLOADED

=> s l8 full

FULL SEARCH INITIATED 13:02:13 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 22 TO ITERATE

100.0% PROCESSED 22 ITERATIONS
SEARCH TIME: 00.00.01

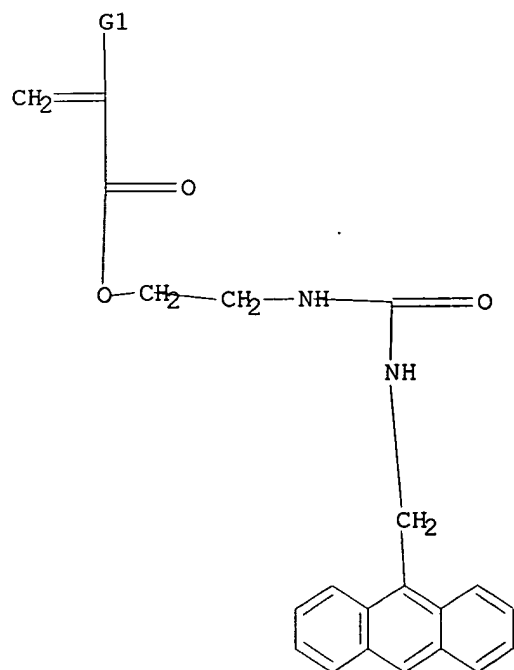
0 ANSWERS

L9 0 SEA SSS FUL L8

=> d l8

L8 HAS NO ANSWERS

L8 STR



G1 H, Me

Structure attributes must be viewed using STN Express query preparation.

=>

L15 ANSWER 1 OF 1 CAPLUS COPYRIGHT 2001 ACS

AN 1998:795188 CAPLUS

DN 130:45293

TI Composition for antireflection or light absorption film and compounds for use in same

IN Padmanaban, Munirathna; Kang, Wen-bing; Tanaka, Hatsuyuki; Kimura, Ken; Pawlowski, Georg

PA Clariant International Ltd., Switz.

SO PCT Int. Appl., 65 pp.

CODEN: PIXXD2

DT Patent

LA Japanese

FAN.CNT 1

some Inventions

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	WO 9854619	A1	19981203	WO 1998-JP2234	19980521
	W: CN, JP, KR, SG, US				
	RW: DE, FR, GB, IT				
	EP 917002	A1	19990519	EP 1998-921751	19980521
	R: DE, FR, GB, IT				
PRAI	JP 1997-137088		19970527		
	WO 1998-JP2234		19980521		

AB A compn. capable of forming an antireflection or light absorption film which satisfactorily absorbs radiations having wavelengths of 100 to 450 nm, is free from the diffusion of a photo-generated acid into the film or the intermixing of a resist with the film, and is excellent in storage stability and step coverage properties; and novel compds. and novel polymers useful for the compn. The compn. contains a compd. which is a (meth)acrylic monomer or polymer having at least one isocyanate or thioisocyanate group bonded to a side chain thereof through an alkylene group, etc., or contains the compd. or polymer which has an aminated or hydroxylated org. chromophore which absorbs light in the wavelength region of 100 to 450 nm and is bonded to the isocyanate or thioisocyanate group. The compn. is applied to a substrate and baked to form a film serving as, e.g., an antireflection film. A chem.-amplification-type resist is applied to this film, and the resist film is exposed to light and then developed to form a resist image with high resolu. Due to the presence of the isocyanate or thioisocyanate group in the compd., the film serving as, e.g., an antireflection film is cured through crosslinking during baking. Due to the presence of the org. chromophore, the film absorbs exposure light in the wavelength region of 100 to 450 nm.

IT **216989-14-9P**, N-(2-Methacryloyloxyethyl)-9-methylanthracene carbamate-methyl methacrylate-methacryloxyethyl isocyanate copolymer
RL: PNU (Preparation, unclassified); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)
(compn. for antireflection or light absorption film)

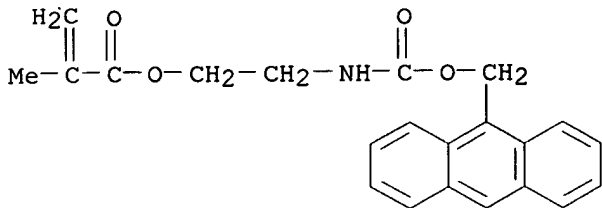
RN 216989-14-9 CAPLUS

CN 2-Propenoic acid, 2-methyl-, 2-[[[(9-anthracenylmethoxy)carbonyl]amino]ethyl ester, polymer with 2-isocyanatoethyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

CM 1

CRN 167859-78-1

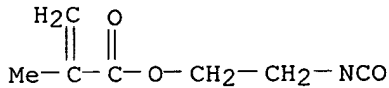
CMF C22 H21 N O4



CM 2

CRN 30674-80-7

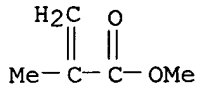
CMF C7 H9 N O3



CM 3

CRN 80-62-6

CMF C5 H8 O2

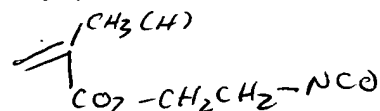


RE.CNT 25

RE

(1) E I Du Pont de Nemours & Co; EP

Polymer WITH double bond



L12 ANSWER 1 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-51-6 REGISTRY

CN 2-Propenoic acid, ethyl ester, telomer with 2,5-furandione,
2-isocyanatoethyl 2-propenoate and 3-(trimethoxysilyl)-1-propanethiol
(9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 1-Propanethiol, 3-(trimethoxysilyl)-, telomer with ethyl 2-propenoate,
2,5-furandione and 2-isocyanatoethyl 2-propenoate (9CI)

CN 2,5-Furandione, telomer with ethyl 2-propenoate, 2-isocyanatoethyl
2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, telomer with ethyl
2-propenoate, 2,5-furandione and 3-(trimethoxysilyl)-1-propanethiol (9CI)

MF C6 H16 O3 S Si . (C6 H7 N O3 . C5 H8 O2 . C4 H2 O3)x

PCT Polyacrylic, Polyvinyl

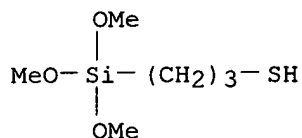
SR CA

LC STN Files: CA, CAPLUS, USPATFULL

CM 1

CRN 4420-74-0

CMF C6 H16 O3 S Si



CM 2

CRN 144093-49-2

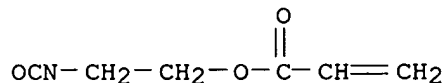
CMF (C6 H7 N O3 . C5 H8 O2 . C4 H2 O3)x

CCI PMS

CM 3

CRN 13641-96-8

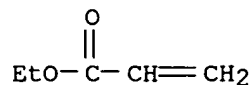
CMF C6 H7 N O3



CM 4

CRN 140-88-5

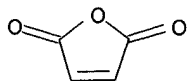
CMF C5 H8 O2



CM 5

CRN 108-31-6

CMF C4 H2 O3



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L12 ANSWER 2 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-50-5 REGISTRY

CN 2-Propenoic acid, ethyl ester, telomer with 2,5-furandione,
2-isocyanatoethyl 2-propenoate and 3-(triethoxysilyl)-1-propanethiol (9CI)
(CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 1-Propanethiol, 3-(triethoxysilyl)-, telomer with ethyl 2-propenoate,
2,5-furandione and 2-isocyanatoethyl 2-propenoate (9CI)

CN 2,5-Furandione, telomer with ethyl 2-propenoate, 2-isocyanatoethyl
2-propenoate and 3-(triethoxysilyl)-1-propanethiol (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, telomer with ethyl
2-propenoate, 2,5-furandione and 3-(triethoxysilyl)-1-propanethiol (9CI)

MF C9 H22 O3 S Si . (C6 H7 N O3 . C5 H8 O2 . C4 H2 O3)x

PCT Polyacrylic, Polyvinyl

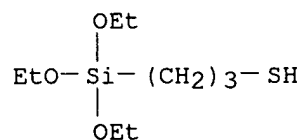
SR CA

LC STN Files: CA, CAPLUS, USPATFULL

CM 1

CRN 14814-09-6

CMF C9 H22 O3 S Si



CM 2

CRN 144093-49-2

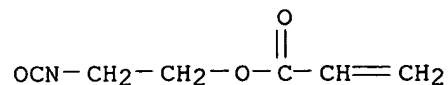
CMF (C6 H7 N O3 . C5 H8 O2 . C4 H2 O3)x

CCI PMS

CM 3

CRN 13641-96-8

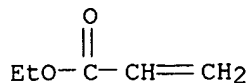
CMF C6 H7 N O3



CM 4

CRN 140-88-5

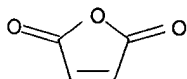
CMF C5 H8 O2



CM 5

CRN 108-31-6

CMF C4 H2 O3



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L12 ANSWER 3 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-49-2 REGISTRY

CN 2-Propenoic acid, ethyl ester, polymer with 2,5-furandione and
2-isocyanatoethyl 2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2,5-Furandione, polymer with ethyl 2-propenoate and 2-isocyanatoethyl
2-propenoate (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with ethyl 2-propenoate
and 2,5-furandione (9CI)

MF (C6 H7 N O3 . C5 H8 O2 . C4 H2 O3)x

CI PMS, COM

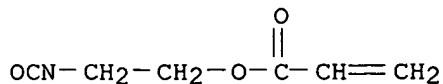
PCT Polyacrylic, Polyvinyl

SR CA

CM 1

CRN 13641-96-8

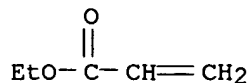
CMF C6 H7 N O3

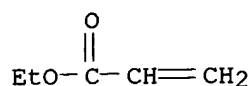


CM 2

CRN 140-88-5

CMF C5 H8 O2

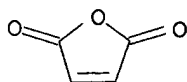




CM 3

CRN 108-31-6

CMF C4 H2 O3



L12 ANSWER 4 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-48-1 REGISTRY

CN 2-Propenoic acid, 2-methyl-, methyl ester, telomer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 1-Propanethiol, 3-(trimethoxysilyl)-, telomer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl-2-propenoate (9CI)

CN 2,5-Furandione, telomer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2-isocyanatoethyl 2-propenoate, methyl 2-methyl-2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

CN 2-Propenoic acid, 2-ethylhexyl ester, telomer with ethenylbenzene, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate, methyl 2-methyl-2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, telomer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione, methyl 2-methyl-2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

CN 2-Propenoic acid, ethyl ester, telomer with ethenylbenzene, 2-ethylhexyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate, methyl 2-methyl-2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

CN Benzene, ethenyl-, telomer with 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate, methyl 2-methyl-2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)

MF (C11 H20 O2 . C8 H8 . C6 H7 N O3 . C5 H8 O2 . C5 H8 O2 . C4 H2 O3)x . C6 H16 O3 S Si

PCT Polyacrylic, Polystyrene, Polyvinyl

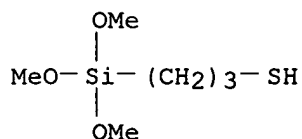
SR CA

LC STN Files: CA, CAPLUS, USPATFULL

CM 1

CRN 4420-74-0

CMF C6 H16 O3 S Si



CM 2

CRN 144093-47-0

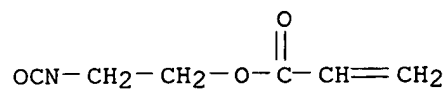
CMF (C11 H20 O2 . C8 H8 . C6 H7 N O3 . C5 H8 O2 . C5 H8 O2 . C4 H2 O3) x

CCI PMS

CM 3

CRN 13641-96-8

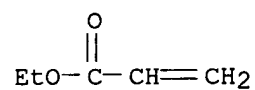
CMF C6 H7 N O3



CM 4

CRN 140-88-5

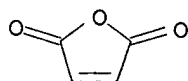
CMF C5 H8 O2



CM 5

CRN 108-31-6

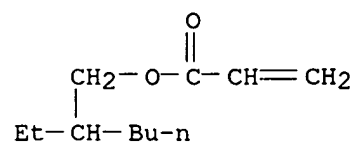
CMF C4 H2 O3



CM 6

CRN 103-11-7

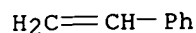
CMF C11 H20 O2



CM 7

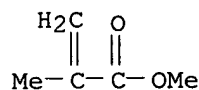
CRN 100-42-5

CMF C8 H8



CM 8

CRN 80-62-6
CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L12 ANSWER 5 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-47-0 REGISTRY

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with ethenylbenzene, ethyl 2-propenoate, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2,5-Furandione, polymer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl-2-propenoate (9CI)

CN 2-Propenoic acid, 2-ethylhexyl ester, polymer with ethenylbenzene, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl-2-propenoate (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with ethenylbenzene, 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione and methyl 2-methyl-2-propenoate (9CI)

CN 2-Propenoic acid, ethyl ester, polymer with ethenylbenzene, 2-ethylhexyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl-2-propenoate (9CI)

CN Benzene, ethenyl-, polymer with 2-ethylhexyl 2-propenoate, ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and methyl 2-methyl 2-propenoate (9CI)

MF (C11 H20 O2 . C8 H8 . C6 H7 N O3 . C5 H8 O2 . C5 H8 O2 . C4 H2 O3)x

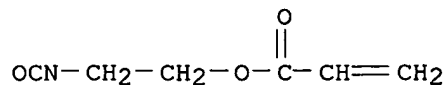
CI PMS, COM

PCT Polyacrylic, Polystyrene, Polyvinyl

SR CA

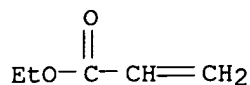
CM 1

CRN 13641-96-8
CMF C6 H7 N O3



CM 2

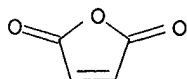
CRN 140-88-5
CMF C5 H8 O2



CM 3

CRN 108-31-6

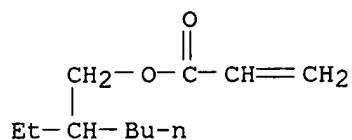
CMF C4 H2 O3



CM 4

CRN 103-11-7

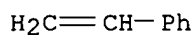
CMF C11 H20 O2



CM 5

CRN 100-42-5

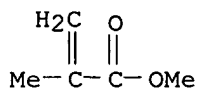
CMF C8 H8



CM 6

CRN 80-62-6

CMF C5 H8 O2



L12 ANSWER 6 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-46-9 REGISTRY

CN 2-Propenoic acid, ethyl ester, telomer with 2,5-furandione,
2-isocyanatoethyl 2-propenoate, methyl 2-propenoate and
3-(trimethoxysilyl)-1-propanethiol (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

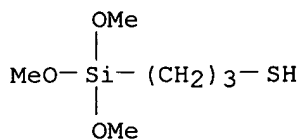
CN 1-Propanethiol, 3-(trimethoxysilyl)-, telomer with ethyl 2-propenoate,

2,5-furandione, 2-isocyanatoethyl 2-propenoate and methyl 2-propenoate (9CI)
 CN 2,5-Furandione, telomer with ethyl 2-propenoate, 2-isocyanatoethyl 2-propenoate, methyl 2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)
 CN 2-Propenoic acid, 2-isocyanatoethyl ester, telomer with ethyl 2-propenoate, 2,5-furandione, methyl 2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)
 CN 2-Propenoic acid, methyl ester, telomer with ethyl 2-propenoate, 2,5-furandione, 2-isocyanatoethyl 2-propenoate and 3-(trimethoxysilyl)-1-propanethiol (9CI)
 MF C6 H16 O3 S Si . (C6 H7 N O3 . C5 H8 O2 . C4 H6 O2 . C4 H2 O3)x
 PCT Polyacrylic, Polyvinyl
 SR CA
 LC STN Files: CA, CAPLUS, USPATFULL

CM 1

CRN 4420-74-0

CMF C6 H16 O3 S Si



CM 2

CRN 144093-45-8

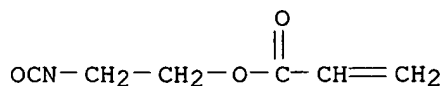
CMF (C6 H7 N O3 . C5 H8 O2 . C4 H6 O2 . C4 H2 O3)x

CCI PMS

CM 3

CRN 13641-96-8

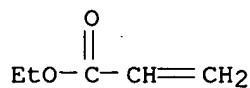
CMF C6 H7 N O3



CM 4

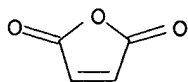
CRN 140-88-5

CMF C5 H8 O2



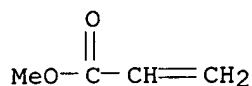
CM 5

CRN 108-31-6
CMF C4 H2 O3



CM 6

CRN 96-33-3
CMF C4 H6 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L12 ANSWER 7 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 144093-45-8 REGISTRY

CN 2-Propenoic acid, ethyl ester, polymer with 2,5-furandione,
2-isocyanatoethyl 2-propenoate and methyl 2-propenoate (9CI) (CA INDEX
NAME)

OTHER CA INDEX NAMES:

CN 2,5-Furandione, polymer with ethyl 2-propenoate, 2-isocyanatoethyl
2-propenoate and methyl 2-propenoate (9CI)

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with ethyl
2-propenoate, 2,5-furandione and methyl 2-propenoate (9CI)

CN 2-Propenoic acid, methyl ester, polymer with ethyl 2-propenoate,
2,5-furandione and 2-isocyanatoethyl 2-propenoate (9CI)

MF (C6 H7 N O3 . C5 H8 O2 . C4 H6 O2 . C4 H2 O3)x

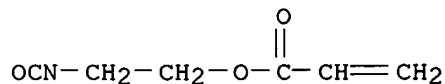
CI PMS, COM

PCT Polyacrylic, Polyvinyl

SR CA

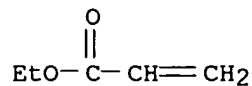
CM 1

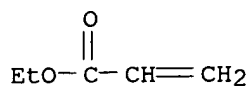
CRN 13641-96-8
CMF C6 H7 N O3



CM 2

CRN 140-88-5
CMF C5 H8 O2

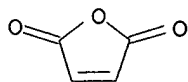




CM 3

CRN 108-31-6

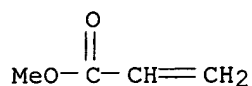
CMF C4 H2 O3



CM 4

CRN 96-33-3

CMF C4 H6 O2



L12 ANSWER 8 OF 8 REGISTRY COPYRIGHT 2001 ACS

RN 139412-76-3 REGISTRY

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with formaldehyde,
2,5-furandione and phenol (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2,5-Furandione, polymer with formaldehyde, 2-isocyanatoethyl 2-propenoate
and phenol (9CI)

CN Formaldehyde, polymer with 2,5-furandione, 2-isocyanatoethyl 2-propenoate
and phenol (9CI)

CN Phenol, polymer with formaldehyde, 2,5-furandione and 2-isocyanatoethyl
2-propenoate (9CI)

MF (C6 H7 N O3 . C6 H6 O . C4 H2 O3 . C H2 O)x

CI PMS

PCT Phenolic resin, Polyacrylic, Polyvinyl

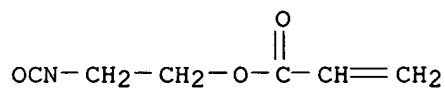
SR CA

LC STN Files: CA, CAPLUS

CM 1

CRN 13641-96-8

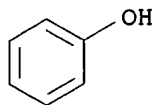
CMF C6 H7 N O3



CM 2

CRN 108-95-2

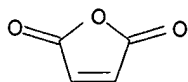
CMF C6 H6 O



CM 3

CRN 108-31-6

CMF C4 H2 O3



CM 4

CRN 50-00-0

CMF C H2 O

H₂C=O

1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=> d his

(FILE 'HOME' ENTERED AT 12:54:25 ON 09 NOV 2001)

FILE 'REGISTRY' ENTERED AT 12:54:48 ON 09 NOV 2001

L1 10 S 167859-78-1/CRN

L2 1 S L1 AND 1/NC

FILE 'CAPLUS' ENTERED AT 12:55:33 ON 09 NOV 2001

L3 1 S L2

FILE 'REGISTRY' ENTERED AT 12:56:06 ON 09 NOV 2001

L4 4 S L1 AND 2/NC

FILE 'CAPLUS' ENTERED AT 12:58:17 ON 09 NOV 2001

S 222032-33-9/REG#

FILE 'REGISTRY' ENTERED AT 12:58:55 ON 09 NOV 2001

L5 1 S 222032-33-9/RN

FILE 'CAPLUS' ENTERED AT 12:58:56 ON 09 NOV 2001

L6 1 S L5

FILE 'REGISTRY' ENTERED AT 13:00:17 ON 09 NOV 2001

L7 4 S L1 AND 3/NC

L8 STRUCTURE UPLOADED

L9 0 S L8 FULL

FILE 'REGISTRY' ENTERED AT 13:14:11 ON 09 NOV 2001

L10 20444 S 108-31-6/CRN
L11 69 S 13641-96-8/CRN
L12 8 S L10 AND L11

=> s 112 and 2/nc
2566152 2/NC

L13 0 L12 AND 2/NC

L4 ANSWER 1 OF 4 REGISTRY COPYRIGHT 2001 ACS

RN 222032-33-9 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-[[[9-anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
2-[[[9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)

MF (C22 H21 N O4 . C5 H8 O2)x

CI PMS

PCT Polyacrylic

SR CA

LC STN Files: CA, CAPLUS

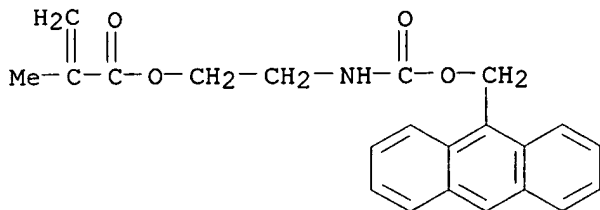
CM 1

CRN 167859-78-1

CMF C22 H21 N O4

NO 9918478 4/89

Inventus



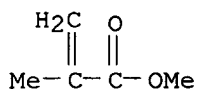
f 070

n70

CM 2

CRN 80-62-6

CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L4 ANSWER 2 OF 4 REGISTRY COPYRIGHT 2001 ACS

RN 222032-29-3 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-[[[9-anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with 2-propenyl 2-methyl-2-propenoate (9CI) (CA INDEX
NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-propenyl ester, polymer with
2-[[[9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)

MF (C22 H21 N O4 . C7 H10 O2)x

CI PMS

PCT Polyacrylic, Polyvinyl

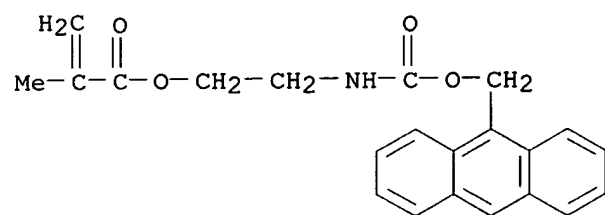
SR CA

LC STN Files: CA, CAPLUS

CM 1

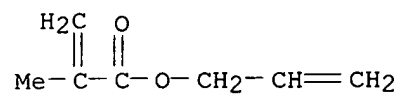
CRN 167859-78-1

CMF C22 H21 N O4



CM 2

CRN 96-05-9
CMF C7 H10 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L3 ANSWER 1 OF 1 CAPLUS COPYRIGHT 2001 ACS
AN 1995:602424 CAPLUS
DN 123:170508
TI Electroluminescent polymers containing pendant electroluminescent side
chains, and electroluminescent devices containing them
IN Cumming, William J.; Gaudiana, Russell A.; Ingwall, Richard T.; Kolb, Eric
S.; Mehta, Parag G.; Minns, Richard A.
PA Polaroid Corp., USA
SO U.S., 13 pp.
CODEN: USXXAM
DT Patent
LA English
FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
	-----	---	-----	-----	-----
PI	US 5414069	A	19950509	US 1993-12038	19930201

Handwritten:
Homograph
used in Reg.

ocyanatoethyl 2-methyl-2-propenoate (9CI)

OTHER NAMES:

CN N-(2-Methacryloyloxyethyl)-9-methylantracene carbamate-methyl
methacrylate-methacryloxyethyl isocyanate copolymer

MF (C22 H21 N O4 . C7 H9 N O3 . C5 H8 O2)x

CI PMS

PCT Polyacrylic

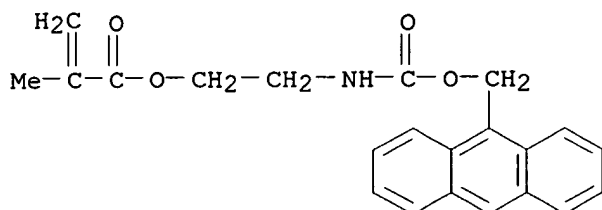
SR CA

LC STN Files: CA, CAPLUS

CM 1

CRN 167859-78-1

CMF C22 H21 N O4

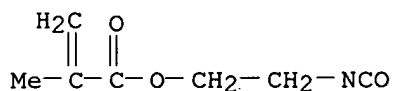


cl 2

CM 2

CRN 30674-80-7

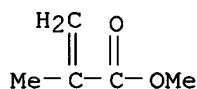
CMF C7 H9 N O3



CM 3

CRN 80-62-6

CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L3 ANSWER 2 OF 2 REGISTRY COPYRIGHT 2001 ACS

RN 216989-12-7 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 2-(acetyloxy)ethyl ester, polymer with
2-[[(9-anthracenylmethoxy)carbonyl]amino]ethyl 2-methyl-2-propenoate (9CI)
(CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-[[(9-anthracenylmethoxy)carbonyl]amino]ethyl
1 ester, polymer with 2-(acetyloxy)ethyl 2-methyl-2-propenoate (9CI)

OTHER NAMES:

L41 ANSWER 6 OF 9 CAPLUS COPYRIGHT 2001 ACS

AN 1994:422534 CAPLUS

DN 121:22534

TI Alkali-developable photopolymerizable composition for manufacture of printed circuit board

IN Mori, Tooru; Matsuda, Hideki

PA Asahi Chemical Ind, Japan

SO Jpn. Kokai Tokkyo Koho, 7 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

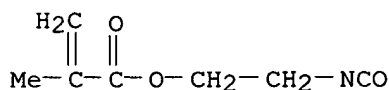
FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 05216229	A2	19930827	JP 1992-46338	19920203
AB	The title compn. contains as essential components (a) a polymer having a repeating structural unit [-CH ₂ -C(CONH-(CH ₂) _n -OCO-CR ₂ :CH ₂)R ₁ -] (n = 1-20; R ₁ , R ₂ = H, Me), a CO ₂ H content of an acid equiv. 200-700 (the wt. of a polymer having 1 equiv of CO ₂ H), and a wt. av. mol. wt. 10000-200,000 and (b) a photopolymn. initiator(s). The compn. is very useful as a resist for manufg. printed circuit boards.				
IT	155904-05-5 155904-06-6				
	RL: USES (Uses)				
	(alkali-developable photopolymn. compn. contg.)				
RN	155904-05-5 CAPLUS				
CN	2-Propenoic acid, 2-methyl-, polymer with butyl 2-propenoate, 2-hydroxyethyl 2-methyl-2-propenoate, 2-isocyanatoethyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)				

CM 1

CRN 30674-80-7

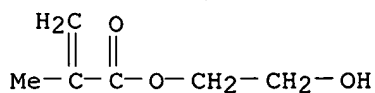
CMF C7 H9 N O3



CM 2

CRN 868-77-9

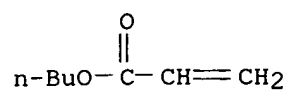
CMF C6 H10 O3



CM 3

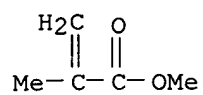
CRN 141-32-2

CMF C7 H12 O2



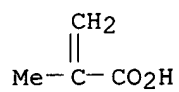
CM 4

CRN 80-62-6
CMF C5 H8 O2



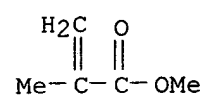
CM 5

CRN 79-41-4
CMF C4 H6 O2



RN 155904-06-6 CAPLUS
CN

CMF C5 H8 O2



=>

DEPR:
Successively, 18.58 parts by weight of tetrahydrophtalic anhydride was added to the solution kept at 115.degree. C., which was kept at that temperature for further 2 hours to complete half-esterification reaction and then cooled down to 70.degree. C. Then, 2.09 parts by weight of 2,2'-bipyridine was added to the solution kept at 70.degree. C., which was kept at that temperature for further 1.5 hours to complete photopolymerizable unsaturated group-introducing reaction and, then cooled to obtain resin having a solid acid

 Details
  Text
  Image
  KWIC

Patent Number: 6,060,315
Date of Patent: May 9, 2000

Reference Cited
U.S. PATENT DOCUMENTS

1971-72 \$1,214,000 1972-73 \$1,214,000
 1973-74 \$1,214,000 1974-75 \$1,214,000
 1975-76 \$1,214,000 1976-77 \$1,214,000
 1977-78 \$1,214,000 1978-79 \$1,214,000
 1979-80 \$1,214,000 1980-81 \$1,214,000
 1981-82 \$1,214,000 1982-83 \$1,214,000
 1983-84 \$1,214,000 1984-85 \$1,214,000
 1985-86 \$1,214,000 1986-87 \$1,214,000
 1987-88 \$1,214,000 1988-89 \$1,214,000
 1989-90 \$1,214,000 1990-91 \$1,214,000
 1991-92 \$1,214,000 1992-93 \$1,214,000
 1993-94 \$1,214,000 1994-95 \$1,214,000
 1995-96 \$1,214,000 1996-97 \$1,214,000
 1997-98 \$1,214,000 1998-99 \$1,214,000
 1999-00 \$1,214,000 2000-01 \$1,214,000
 2001-02 \$1,214,000 2002-03 \$1,214,000
 2003-04 \$1,214,000 2004-05 \$1,214,000
 2005-06 \$1,214,000 2006-07 \$1,214,000
 2007-08 \$1,214,000 2008-09 \$1,214,000
 2009-10 \$1,214,000 2010-11 \$1,214,000
 2011-12 \$1,214,000 2012-13 \$1,214,000
 2013-14 \$1,214,000 2014-15 \$1,214,000
 2015-16 \$1,214,000 2016-17 \$1,214,000
 2017-18 \$1,214,000 2018-19 \$1,214,000
 2019-20 \$1,214,000 2020-21 \$1,214,000
 2021-22 \$1,214,000 2022-23 \$1,214,000
 2023-24 \$1,214,000 2024-25 \$1,214,000
 2025-26 \$1,214,000 2026-27 \$1,214,000
 2027-28 \$1,214,000 2028-29 \$1,214,000
 2029-30 \$1,214,000 2030-31 \$1,214,000
 2031-32 \$1,214,000 2032-33 \$1,214,000
 2033-34 \$1,214,000 2034-35 \$1,214,000
 2035-36 \$1,214,000 2036-37 \$1,214,000
 2037-38 \$1,214,000 2038-39 \$1,214,000
 2039-40 \$1,214,000 2040-41 \$1,214,000
 2041-42 \$1,214,000 2042-43 \$1,214,000
 2043-44 \$1,214,000 2044-45 \$1,214,000
 2045-46 \$1,214,000 2046-47 \$1,214,000
 2047-48 \$1,214,000 2048-49 \$1,214,000
 2049-50 \$1,214,000 2050-51 \$1,214,000
 2051-52 \$1,214,000 2052-53 \$1,214,000
 2053-54 \$1,214,000 2054-55 \$1,214,000
 2055-56 \$1,214,000 2056-57 \$1,214,000
 2057-58 \$1,214,000 2058-59 \$1,214,000
 2059-60 \$1,214,000 2060-61 \$1,214,000
 2061-62 \$1,214,000 2062-63 \$1,214,000
 2063-64 \$1,214,000 2064-65 \$1,214,000
 2065-66 \$1,214,000 2066-67 \$1,214,000
 2067-68 \$1,214,000 2068-69 \$1,214,000
 2069-70 \$1,214,000 2070-71 \$1,214,000
 2071-72 \$1,214,000 2072-73 \$1,214,000
 2073-74 \$1,214,000 2074-75 \$1,214,000
 2075-76 \$1,214,000 2076-77 \$1,214,000
 2077-78 \$1,214,000 2078-79 \$1,214,000
 2079-80 \$1,214,000 2080-81 \$1,214,000
 2081-82 \$1,214,000 2082-83 \$1,214,000
 2083-84 \$1,214,000 2084-85 \$1,214,000
 2085-86 \$1,214,000 2086-87 \$1,214,000
 2087-88 \$1,214,000 2088-89 \$1,214,000
 2089-90 \$1,214,000 2090-91 \$1,214,000
 2091-92 \$1,214,000 2092-93 \$1,214,000
 2093-94 \$1,214,000 2094-95 \$1,214,000
 2095-96 \$1,214,000 2096-97 \$1,214,000
 2097-98 \$1,214,000 2098-99 \$1,214,000
 2099-00 \$1,214,000 2100-01 \$1,214,000
 2101-02 \$1,214,000 2102-03 \$1,214,000
 2103-04 \$1,214,000 2104-05 \$1,214,000
 2105-06 \$1,214,000 2106-07 \$1,214,000
 2107-08 \$1,214,000 2108-09 \$1,214,000
 2109-10 \$1,214,000 2110-11 \$1,214,000
 2111-12 \$1,214,000 2112-13 \$1,214,000
 2113-14 \$1,214,000 2114-15 \$1,214,000
 2115-16 \$1,214,000 2116-17 \$1,214,000
 2117-18 \$1,214,000 2118-19 \$1,214,000
 2119-20 \$1,214,000 2120-21 \$1,214,000
 2121-22 \$1,214,000 2122-23 \$1,214,000
 2123-24 \$1,214,000 2124-25 \$1,214,000
 2125-26 \$1,214,000 2126-27 \$1,214,000
 2127-28 \$1,214,000 2128-29 \$1,214,000
 2129-30 \$1,214,000 2130-31 \$1,214,000
 2131-32 \$1,214,000 2132-33 \$1,214,000
 2133-34 \$1,214,000 2134-35 \$1,214,000
 2135-36 \$1,214,000 2136-37 \$1,214,000
 2137-38 \$1,214,000 2138-39 \$1,214,000
 2139-40 \$1,214,000 2140-41 \$1,214,000
 2141-42 \$1,214,000 2142-43 \$1,214,000
 2143-44 \$1,214,000 2144-45 \$1,214,000
 2145-46 \$1,214,000 2146-47 \$1,214,000
 2147-48 \$1,214,000 2148-49 \$1,214,000
 2149-50 \$1,214,000 2150-51 \$1,214,000
 2151-52 \$1,214,000 2152-53 \$1,214,000
 2153-54 \$1,214,000 2154-55 \$1,214,000
 2155-56 \$1,214,000 2156-57 \$1,214,000
 2157-58 \$1,214,000 2158-59 \$1,214,000
 2159-60 \$1,214,000 2160-61 \$1,214,000
 2161-62 \$1,214,000 2162-63 \$1,214,000
 2163-64 \$1,214,000 2164-65 \$1,214,000
 2165-66 \$1,214,000 2166-67 \$1,214,000
 2167-68 \$1,214,000 2168-69 \$1,214,000
 2169-70 \$1,214,000 2170-71 \$1,214,000
 2171-72 \$1,214,000 2172-73 \$1,214,000
 2173-74 \$1,214,000 2174-75 \$1,214,000
 2175-76 \$1,2

ABSTRACT

2. *How do you feel about the way the company is doing?*

visually accessible gray cell (Q) a photoreceptor

predictability, in official public formality, by

624 is capable of producing word patterns having good

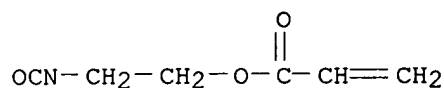
[illegible]

and a flexible printed circuit board.

11 Class, No Drawings

15 **Classing No Derivatives**

L52 ANSWER 1 OF 1 REGISTRY COPYRIGHT 2001 ACS
 RN 13641-96-8 REGISTRY
 CN 2-Propenoic acid, 2-isocyanatoethyl ester (9CI) (CA INDEX NAME)
 OTHER CA INDEX NAMES:
 CN Acrylic acid, 2-isocyanatoethyl ester (6CI)
 CN Acrylic acid, ester with 2-hydroxyethyl isocyanate (8CI)
 CN Isocyanic acid, 2-hydroxyethyl ester acrylate (ester)
 OTHER NAMES:
 CN **2-Isocyanatoethyl acrylate**
 FS 3D CONCORD
 MF **C6 H7 N O3**
 CI COM
 LC STN Files: BEILSTEIN*, CA, CAOLD, CAPLUS, IFICDB, IFIPAT, IFIUDB,
 TOXLIT, USPATFULL
 (*File contains numerically searchable property data)



****PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT****

54 REFERENCES IN FILE CA (1967 TO DATE)
 25 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
 54 REFERENCES IN FILE CAPLUS (1967 TO DATE)
 1 REFERENCES IN FILE CAOLD (PRIOR TO 1967)

L60 ANSWER 1 OF 2 CAPLUS COPYRIGHT 2001 ACS

AN 1998:47847 CAPLUS

DN 128:134388

TI Photosensitive resin composition and photosensitive element using same

IN Tsukada, Katsue; Otomo, Satoshi; Watanabe, Mitsuaki

PA Hitachi Chemical Co., Ltd., Japan

SO Jpn. Kokai Tokkyo Koho, 7 pp.

CODEN: JKXXAF

DT Patent

LA Japanese

FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 10010725	A2	19980116	JP 1996-167463	19960627
AB	The title compn. contains (a) a photopolyimg. unsat. compd. prepd. by the addn. reaction of .gtoreq.1 selected from o-cresol-, phenol-, and halogenated phenol-novolak-type epoxy resins with an unsatd. carboxylic acid (acid equiv/epoxy equiv ratio = 0.1-1.0) and the reaction of the sec-OH group of the resulting unsatd. compd. with isocyanate Et acrylate (isocyanate equiv/OH equiv ratio = 0.1-1.0) and (b) a photopolymn. initiator generating a free radical upon active ray irradiation. The title element comprises a film support laminated with the compn. The compn. shows improved photo-curing properties and thermal resistance. Thus, a photosensitive resin compn. comprised a photopolyimg. compd. prepd. by reacting a reactant of EOCN 104 (o-cresol-novolak-type epoxy resin) and acrylic acid with isocyanato Et acrylate and 2,4-diethylthioxanthone.				
IT	202121-81-1P, Acrylic acid-EOCN 104-isocyanatoethyl acrylate copolymer 202121-82-2P, EOCN 104-isocyanatoethyl acrylate-methacrylic acid copolymer				
RL	PNU (Preparation, unclassified); TEM (Technical or engineered material use); PREP (Preparation); USES (Uses)				
	(photoresist compn. contg. polyurethane novolak epoxy resin)				
RN	202121-81-1 CAPLUS				
CN	2-Propenoic acid, polymer with EOCN 104 and 2-isocyanatoethyl 2-propenoate (9CI) (CA INDEX NAME)				

CM 1

CRN 70903-88-7

CMF Unspecified

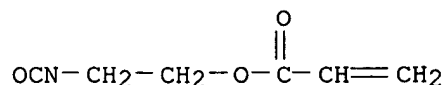
CCI MAN

*** STRUCTURE DIAGRAM IS NOT AVAILABLE ***

CM 2

CRN 13641-96-8

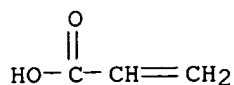
CMF C6 H7 N O3



CM 3

CRN 79-10-7

CMF C3 H4 O2



RN 202121-82-2 CAPLUS
 CN 2-Propenoic acid, 2-methyl-, polymer with EOCN 104 and 2-isocyanatoethyl
 2-propenoate (9CI) (CA INDEX NAME)

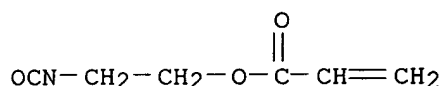
CM 1

CRN 70903-88-7
 CMF Unspecified
 CCI MAN

*** STRUCTURE DIAGRAM IS NOT AVAILABLE ***

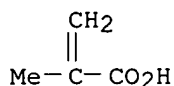
CM 2

CRN 13641-96-8
 CMF C6 H7 N O3



CM 3

CRN 79-41-4
 CMF C4 H6 O2



L60 ANSWER 2 OF 2 CAPLUS COPYRIGHT 2001 ACS
 AN 1992:140142 CAPLUS
 DN 116:140142
 TI Alkali-developable photosensitive resist compositions
 IN Iwaya, Yoshiaki
 PA Unitika Ltd., Japan
 SO Jpn. Kokai Tokkyo Koho, 12 pp.
 CODEN: JKXXAF
 DT Patent
 LA Japanese
 FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
PI	JP 03265860	A2	19911126	JP 1990-67956	19900315
AB	The compns. consist of (a) 100 parts photopolymg. unsatd. copolymers consisting of repeating units I and II in (9-1):(1-9) mol ratio [R1-3 = H, C1-5-alkyl, halo; X = dicarboxylic acid minus a carboxylic group; A = (meth)acryloyl], (b) 5-100 parts epoxy compd., and (c) 0.1-30 parts photopolymn. initiator or sensitizer. These compns., mainly for prepn. of protective mask in fabrication of printed circuits and for many other				

purposes, provide resists with high resistance to chems., high insulation, high resistance to solder bath, and mech. strength, can be further cured by heat.

IT 139412-76-3 139556-84-6

RL: USES (Uses)

(alkali-developable photoresists contg.)

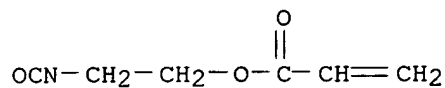
RN 139412-76-3 CAPLUS

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with formaldehyde, 2,5-furandione and phenol (9CI) (CA INDEX NAME)

CM 1

CRN 13641-96-8

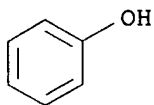
CMF C6 H7 N O3



CM 2

CRN 108-95-2

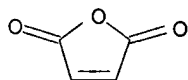
CMF C6 H6 O



CM 3

CRN 108-31-6

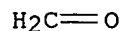
CMF C4 H2 O3



CM 4

CRN 50-00-0

CMF C H2 O

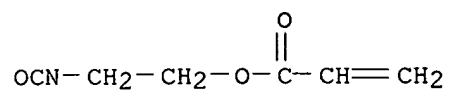


RN 139556-84-6 CAPLUS

CN 2-Propenoic acid, 2-isocyanatoethyl ester, polymer with formaldehyde, phenol and tetrahydro-1,3-isobenzofurandione (9CI) (CA INDEX NAME)

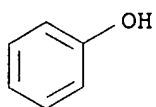
CM 1

CRN 13641-96-8
CMF C6 H7 N O3



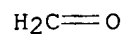
CM 2

CRN 108-95-2
CMF C6 H6 O



CM 3

CRN 50-00-0
CMF C H2 O

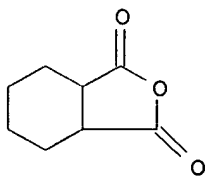


CM 4

CRN 26266-63-7
CMF C8 H8 O3
CCI IDS
CDES 8:ID

CM 5

CRN 85-42-7
CMF C8 H10 O3



=>

(FILE 'HOME' ENTERED AT 11:55:49 ON 05 NOV 2001)

FILE 'REGISTRY' ENTERED AT 11:55:58 ON 05 NOV 2001

L1 SCREEN 963 AND 970 AND 2067
L2 STRUCTURE UPLOADED
L3 QUE L2 AND L1
L4 50 S L3 SAM
L5 3 S L4 AND 1/NC
L6 45 S METHACRYLOYLOXYETHYL ISOCYANATE
L7 1 S L6 AND 1/NC

FILE 'CAPLUS' ENTERED AT 12:00:02 ON 05 NOV 2001

L8 28 S L7

FILE 'REGISTRY' ENTERED AT 12:10:21 ON 05 NOV 2001

L9 2779 S L3 FULL

FILE 'CAPLUS' ENTERED AT 12:10:48 ON 05 NOV 2001

L10 1337 S L9
L11 34168 S ANTIREFLECTIVE OR ANTIREFLECTION OR PHOTORESIST
L12 67 S L10 AND L11

FILE 'REGISTRY' ENTERED AT 12:12:26 ON 05 NOV 2001

FILE 'CAPLUS' ENTERED AT 12:12:29 ON 05 NOV 2001
S 88007-27-6/REG#

FILE 'REGISTRY' ENTERED AT 12:13:06 ON 05 NOV 2001

L13 1 S 88007-27-6/RN

FILE 'CAPLUS' ENTERED AT 12:13:06 ON 05 NOV 2001

L14 28 S L13
L15 2 S L11 AND L14

FILE 'REGISTRY' ENTERED AT 12:16:21 ON 05 NOV 2001

FILE 'CAPLUS' ENTERED AT 12:16:28 ON 05 NOV 2001

L16 5 S L6 AND L11

FILE 'REGISTRY' ENTERED AT 12:22:18 ON 05 NOV 2001

L17 1388 S 30674-80-7/CRN
L18 56797 S 80-62-6/CRN
L19 397 S L17 AND L18
L20 2 S L19 AND 2/NC

FILE 'CAPLUS' ENTERED AT 12:24:25 ON 05 NOV 2001

L21 4144 S RADIATION ABSORBING OR RADIATION SENSITIVE
L22 2 S L20 AND (L21 OR L11)

FILE 'REGISTRY' ENTERED AT 12:27:49 ON 05 NOV 2001

L23 20387 S 108-31-6/CRN
L24 20 S L17 AND L23

FILE 'CAPLUS' ENTERED AT 12:28:41 ON 05 NOV 2001

L25 0 S L24 AND (L21 OR L11)

FILE 'REGISTRY' ENTERED AT 12:29:28 ON 05 NOV 2001

L26 1 S L17 AND 1/NC
L27 9 S L19 AND L23

L28 FILE 'CAPLUS' ENTERED AT 12:31:33 ON 05 NOV 2001
 0 S L27 AND (L21 OR L11)
 S 88007-27-6/REG#

L29 FILE 'REGISTRY' ENTERED AT 12:32:31 ON 05 NOV 2001
 1 S 88007-27-6/RN

L30 FILE 'CAPLUS' ENTERED AT 12:32:32 ON 05 NOV 2001
 28 S L29
 L31 2 S L30 AND (L21 OR L11)

L32 FILE 'REGISTRY' ENTERED AT 12:33:49 ON 05 NOV 2001
 2 S ANTHRACENYL METHACRYLATE
 L33 0 S METHYL ANTHRACENYL METHACRYLATE

L34 FILE 'REGISTRY' ENTERED AT 12:35:00 ON 05 NOV 2001
 SCREEN 963 AND 970 AND 2067
 L35 STRUCTURE UPLOADED
 L36 QUE L35 AND L34
 L37 1 S L36 SAM
 L38 20 S 30674-80-7/CRN AND 108-31-6/CRN
 L39 397 S 30674-80-7/CRN AND 80-62-6/CRN

L40 FILE 'CAPLUS' ENTERED AT 12:39:19 ON 05 NOV 2001
 0 S L38 AND (L11 OR L21)
 L41 9 S L39 AND (L11 OR L21)
 S 88007-27-6/REG#

L42 FILE 'REGISTRY' ENTERED AT 12:52:07 ON 05 NOV 2001
 1 S 88007-27-6/RN

L43 FILE 'CAPLUS' ENTERED AT 12:52:07 ON 05 NOV 2001
 28 S L42
 L44 0 S (L11 OR L21) AND L38

L45 FILE 'REGISTRY' ENTERED AT 12:59:00 ON 05 NOV 2001
 0 S L38 AND 2/NC
 L46 2 S L39 AND 2/NC

L47 FILE 'CAPLUS' ENTERED AT 12:59:47 ON 05 NOV 2001
 S 100042-81-7/REG#

L48 FILE 'REGISTRY' ENTERED AT 13:00:02 ON 05 NOV 2001
 1 S 100042-81-7/RN

L49 FILE 'CAPLUS' ENTERED AT 13:00:04 ON 05 NOV 2001
 24 S L47
 S 167859-78-1/REG#

L50 FILE 'REGISTRY' ENTERED AT 13:17:02 ON 05 NOV 2001
 1 S 167859-78-1/RN

L51 FILE 'CAPLUS' ENTERED AT 13:17:04 ON 05 NOV 2001
 2 S L49

L52 FILE 'REGISTRY' ENTERED AT 13:21:27 ON 05 NOV 2001
 17 S ISOCYANATOETHYL ACRYLATE
 L53 1 S L51 AND 1/NC
 69 S 13641-96-8/CRN

L54 FILE 'CAPLUS' ENTERED AT 13:24:08 ON 05 NOV 2001
 35 S L53

L55 2 S L54 AND (L11 OR L21)

FILE 'REGISTRY' ENTERED AT 13:35:29 ON 05 NOV 2001

FILE 'REGISTRY' ENTERED AT 13:36:13 ON 05 NOV 2001

L56 0 S 13641-96-4/CRN
L57 0 S 13641-96-4
L58 69 S 13641-96-8/CRN
L59 1388 S 30674-80-7/CRN

FILE 'CAPLUS' ENTERED AT 13:38:56 ON 05 NOV 2001

L60 2 S (L11 OR L21) AND L58
L61 37 S (L11 OR L21) AND L59

FILE 'REGISTRY' ENTERED AT 13:42:14 ON 05 NOV 2001

L62 7 S L58 AND (79-10-7/CRN OR 79-41-4/CRN)
L63 1 S L62 AND 2/NC
L64 290 S L59 AND (79-10-7/CRN OR 79-41-4/CRN)
L65 3 S L64 AND 2/NC

FILE 'CAPLUS' ENTERED AT 13:44:27 ON 05 NOV 2001

=> s 165

L66 7 L65

=> d 1-7 bib ab

L66 ANSWER 1 OF 7 CAPLUS COPYRIGHT 2001 ACS

AN 2000:755235 CAPLUS

DN 133:342501

TI Planographic printing plate precursor containing metal compounds, and
process for producing planographic printing plates

IN Kawamura, Koichi

PA Fuji Photo Film Co., Ltd., Japan

SO Eur. Pat. Appl., 28 pp.

CODEN: EPXXDW

DT Patent

LA English

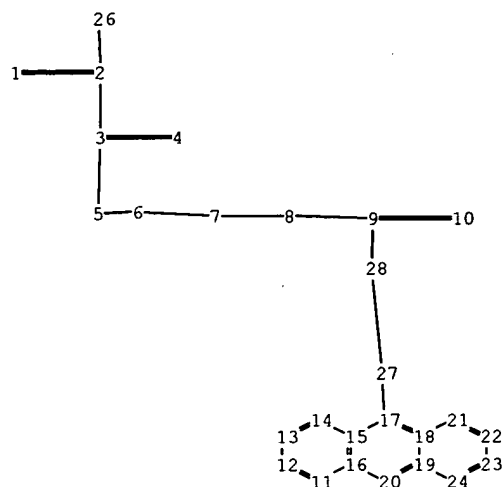
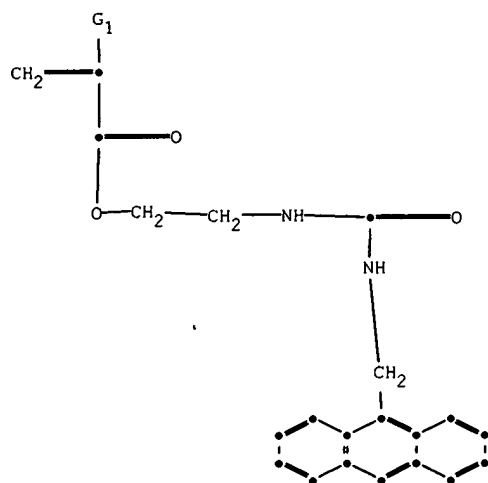
FAN.CNT 1

	PATENT NO.	KIND	DATE	APPLICATION NO.	DATE
	-----		-----	-----	-----
PI	EP 1046496	A1	20001025	EP 2000-108086	20000425
	R: AT, BE, CH, DE, DK, ES, FR, GB, GR, IT, LI, LU, NL, SE, MC, PT, IE, SI, LT, LV, FI, RO				

(FILE 'HOME' ENTERED AT 16:26:32 ON 05 NOV 2001)

FILE 'REGISTRY' ENTERED AT 16:26:46 ON 05 NOV 2001

L1	STRUCTURE UPLOADED
L2	STRUCTURE UPLOADED
L3	0 S L2 SAM
L4	0 S L2 FULL
L5	0 S L1 SAM
L6	0 S L1 FULL



chain nodes :

1 2 3 4 5 6 7 8 9 10 26 27 28

ring nodes :

11 12 13 14 15 16 17 18 19 20 21 22 23 24

chain bonds :

1-2 2-3 2-26 3-4 3-5 5-6 6-7 7-8 8-9 9-10 9-28 17-27 27-28

ring bonds :

11-12 11-16 12-13 13-14 14-15 15-16 15-17 16-20 17-18 18-19
18-21 19-20 19-24 21-22 22-23 23-24

exact/norm bonds :

2-26 3-4 3-5 8-9 9-10 9-28

exact bonds :

1-2 2-3 5-6 6-7 7-8 17-27 27-28

normalized bonds :

11-12 11-16 12-13 13-14 14-15 15-16 15-17 16-20 17-18 18-19
18-21 19-20 19-24 21-22 22-23 23-24

G1:H,CH3

Match level :

1:Atom 2:Atom 3:Atom 4:Atom 5:Atom 6:Atom 7:Atom 8:Atom 9:Atom
10:Atom 11:Atom 12:Atom 13:Atom 14:Atom 15:Atom 16:Atom 17:Atom
18:Atom 19:Atom 20:Atom 21:Atom 22:Atom 23:Atom 24:Atom 26:CLASS
27:CLASS 28:CLASS

Claim 19

Uploading 237c.str

L1 STRUCTURE UPLOADED

=> s l1 full

FULL SEARCH INITIATED 19:19:11 FILE 'REGISTRY'
FULL SCREEN SEARCH COMPLETED - 22 TO ITERATE

100.0% PROCESSED 22 ITERATIONS
SEARCH TIME: 00.00.01

0 ANSWERS

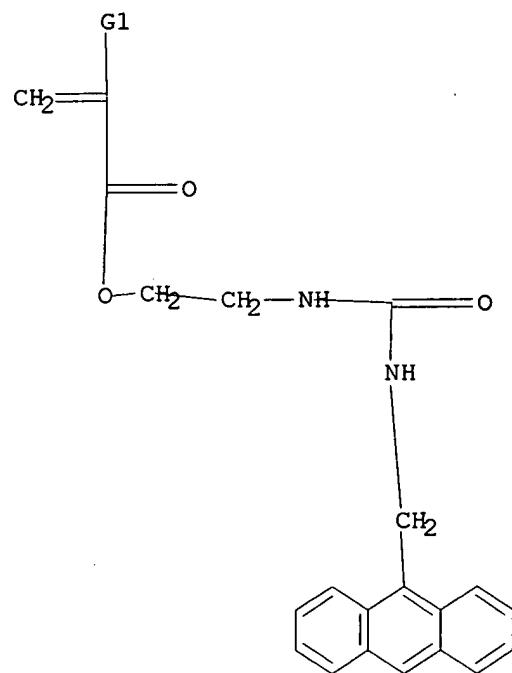
0 hits

L2 0 SEA SSS FUL L1

=> d l1

L1 HAS NO ANSWERS

L1 STR



G1 H, Me

Structure attributes must be viewed using STN Express query preparation.

=>

Polymer 43 in cl 10 for
cl 17

0 Hits 2M

L1 ANSWER 1 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 254756-23-5 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with
2-hydroxyethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI) (CA
INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI)

CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI)

CN 2-Propenoic acid, 2-methyl-, phenylmethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and 2-isocyanatoethyl 2-methyl-2-propenoate (9CI)

OTHER NAMES:

CN 9-Anthrylmethyl methacrylate-benzyl methacrylate-ethylene glycol
methacrylate-2-isocyanatoethyl methacrylate copolymer

MF (C19 H16 O2 . C11 H12 O2 . C7 H9 N O3 . C6 H10 O3)x

CI PMS

PCT Polyacrylic

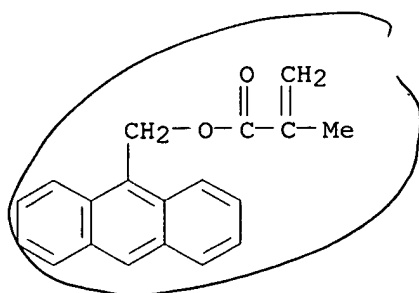
SR CA

LC STN Files: CA, CAPLUS

CM 1

CRN 31645-35-9

CMF C19 H16 O2

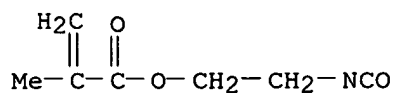


Polymer w/ monomer "P"

CM 2

CRN 30674-80-7

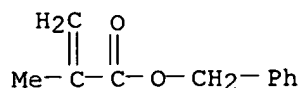
CMF C7 H9 N O3



CM 3

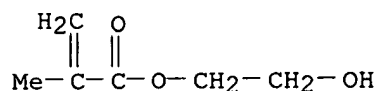
CRN 2495-37-6

CMF C11 H12 O2



CM 4

CRN 868-77-9
CMF C6 H10 O3

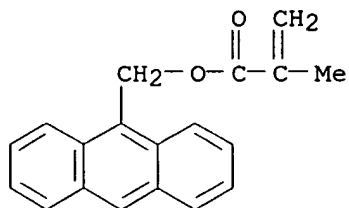


1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 2 OF 3 REGISTRY COPYRIGHT 2001 ACS
RN 254756-22-4 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with
2-hydroxyethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX
NAME)
OTHER CA INDEX NAMES:
CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and 2-isocyanatoethyl 2-methyl-2-propenoate (9CI)
MF (C19 H16 O2 . C7 H9 N O3 . C6 H10 O3 . C5 H8 O2)x
CI PMS
PCT Polyacrylic
SR CA
LC STN Files: CA, CAPLUS

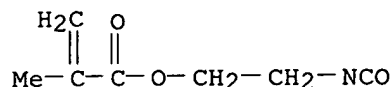
CM 1

CRN 31645-35-9
CMF C19 H16 O2



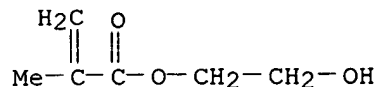
CM 2

CRN 30674-80-7
CMF C7 H9 N O3



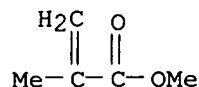
CM 3

CRN 868-77-9
CMF C6 H10 O3



CM 4

CRN 80-62-6
CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 3 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 254756-21-3 REGISTRY

CN Butanoic acid, 3-oxo-, 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, methyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with 2-isocyanatoethyl 2-methyl-2-propenoate, methyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

OTHER NAMES:

CN 2-Acetoacetoxyethyl methacrylate-9-anthrylmethyl methacrylate-2-isocyanatoethyl methacrylate-methyl methacrylate copolymer

MF (C19 H16 O2 . C10 H14 O5 . C7 H9 N O3 . C5 H8 O2)x

CI PMS

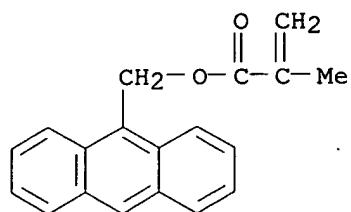
PCT Polyacrylic

SR CA

LC STN Files: CA, CAPLUS

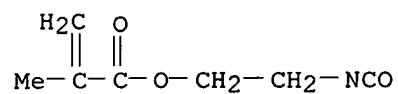
CM 1

CRN 31645-35-9
CMF C19 H16 O2



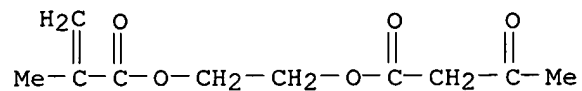
CM 2

CRN 30674-80-7
CMF C7 H9 N O3



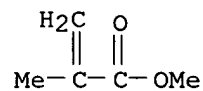
CM 3

CRN 21282-97-3
CMF C10 H14 O5



CM 4

CRN 80-62-6
CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=>

(FILE 'HOME' ENTERED AT 18:41:48 ON 08 NOV 2001)

FILE 'REGISTRY' ENTERED AT 18:41:54 ON 08 NOV 2001

L1 20429 S 108-31-6/CRN
L2 1388 S 30674-80-7/CRN
L3 20 S L1 AND L2
L4 0 S L3 AND 2/NC
L5 0 S L3 AND 3/NC

=>

Claim 10

0 Hib for

copoly of

maleic anhydride +

CH₃ CH₃

CO₂

CH₂CH₂-N=C=O

17 and 18

L9

3 L7 AND L8

=> d 1-3

L9 ANSWER 1 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 254756-23-5 REGISTRY

CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with
2-hydroxyethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI) (CA
INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and phenylmethyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, phenylmethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and 2-isocyanatoethyl 2-methyl-2-propenoate (9CI)

OTHER NAMES:

CN 9-Anthrylmethyl methacrylate-benzyl methacrylate-ethylene glycol
methacrylate-2-isocyanatoethyl methacrylate copolymer

MF (C19 H16 O2 . C11 H12 O2 . C7 H9 N O3 . C6 H10 O3)x

CI PMS

PCT Polyacrylic

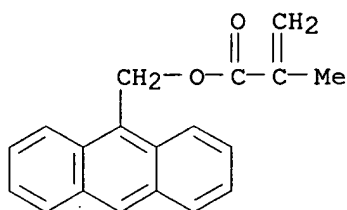
SR CA

LC STN Files: CA, CAPLUS

CM 1

CRN 31645-35-9

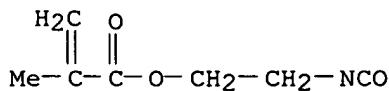
CMF C19 H16 O2



CM 2

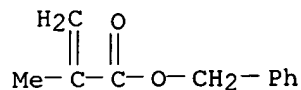
CRN 30674-80-7

CMF C7 H9 N O3



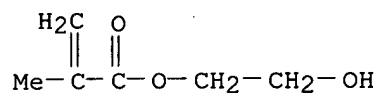
CM 3

CRN 2495-37-6
CMF C11 H12 O2



CM 4

CRN 868-77-9
CMF C6 H10 O3

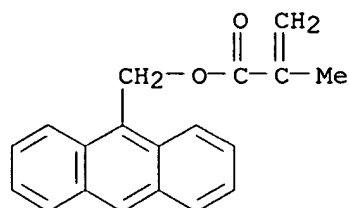


1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L9 ANSWER 2 OF 3 REGISTRY COPYRIGHT 2001 ACS
RN 254756-22-4 REGISTRY
CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with
2-hydroxyethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX
NAME)
OTHER CA INDEX NAMES:
CN 2-Propenoic acid, 2-methyl-, 2-hydroxyethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI)
CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
9-anthracenylmethyl 2-methyl-2-propenoate, 2-hydroxyethyl
2-methyl-2-propenoate and 2-isocyanatoethyl 2-methyl-2-propenoate (9CI)
MF (C19 H16 O2 . C7 H9 N O3 . C6 H10 O3 . C5 H8 O2)x
CI PMS
PCT Polyacrylic
SR CA
LC STN Files: CA, CAPLUS

CM 1

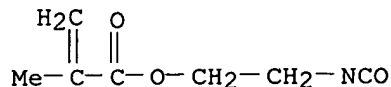
CRN 31645-35-9
CMF C19 H16 O2



CM 2

CRN 30674-80-7

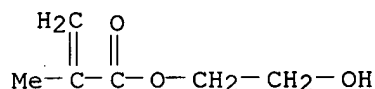
CMF C7 H9 N O3



CM 3

CRN 868-77-9

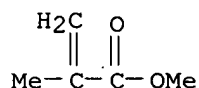
CMF C6 H10 O3



CM 4

CRN 80-62-6

CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)

1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L9 ANSWER 3 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 254756-21-3 REGISTRY

CN Butanoic acid, 3-oxo-, 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl 2-methyl-2-propenoate and methyl 2-methyl-2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 2-methyl-, 2-isocyanatoethyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, methyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

CN 2-Propenoic acid, 2-methyl-, 9-anthracenylmethyl ester, polymer with 2-isocyanatoethyl 2-methyl-2-propenoate, methyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with 9-anthracenylmethyl 2-methyl-2-propenoate, 2-isocyanatoethyl 2-methyl-2-propenoate and 2-[(2-methyl-1-oxo-2-propenyl)oxy]ethyl 3-oxobutanoate (9CI)

OTHER NAMES:

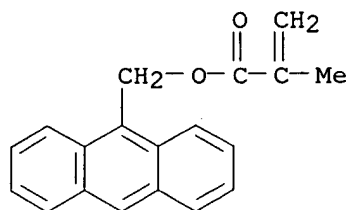
CN 2-Acetoacetoxyethyl methacrylate-9-anthrylmethyl methacrylate-2-

isocyanatoethyl methacrylate-methyl methacrylate copolymer

MF (C19 H16 O2 . C10 H14 O5 . C7 H9 N O3 . C5 H8 O2)x
 CI PMS
 PCT Polyacrylic
 SR CA
 LC STN Files: CA, CAPLUS

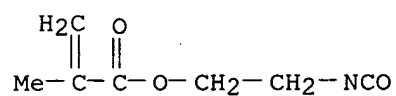
CM 1

CRN 31645-35-9
 CMF C19 H16 O2



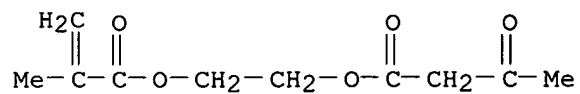
CM 2

CRN 30674-80-7
 CMF C7 H9 N O3



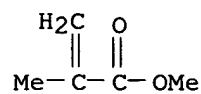
CM 3

CRN 21282-97-3
 CMF C10 H14 O5



CM 4

CRN 80-62-6
 CMF C5 H8 O2



1 REFERENCES IN FILE CA (1967 TO DATE)
1 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 970 AND 2067

L10 SCREEN CREATED

=>

Uploading C:\STNEXP4\QUERIES\237p.str

L11 STRUCTURE UPLOADED

=> que L11 AND L10

L12 QUE L11 AND L10

=>Testing the current file.... screen

ENTER SCREEN EXPRESSION OR (END):end

=> screen 970 AND 2067

L13 SCREEN CREATED

=>

Uploading C:\STNEXP4\QUERIES\237q.str

L14 STRUCTURE UPLOADED

=> que L14 AND L13

L15 QUE L14 AND L13

=> d his

(FILE 'HOME' ENTERED AT 16:46:59 ON 07 NOV 2001)

FILE 'REGISTRY' ENTERED AT 16:47:20 ON 07 NOV 2001

L1 SCREEN 970 AND 2067
L2 STRUCTURE UPLOADED
L3 QUE L2 AND L1
L4 SCREEN 970 AND 2067
L5 STRUCTURE UPLOADED
L6 QUE L5 AND L4
L7 3029 S L3 FULL
L8 131 S L6 FULL
L9 3 S L7 AND L8 ✓
L10 SCREEN 970 AND 2067
L11 STRUCTURE UPLOADED
L12 QUE L11 AND L10
L13 SCREEN 970 AND 2067
L14 STRUCTURE UPLOADED
L15 QUE L14 AND L13

L1 ANSWER 1 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 37806-82-9 REGISTRY

CN 2-Propenoic acid, 2-methyl-, methyl ester, polymer with
9-anthracenylmethyl 2-propenoate (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 2-Propenoic acid, 9-anthracenylmethyl ester, polymer with methyl
2-methyl-2-propenoate (9CI)

OTHER NAMES:

CN 9-Anthrylmethyl acrylate-methyl methacrylate copolymer

CN 9-Anthrylmethyl acrylate-methyl methacrylate polymer

MF (C18 H14 O2 . C5 H8 O2)x

CI PMS

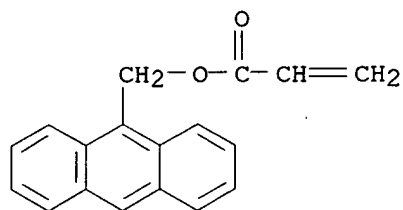
PCT Polyacrylic

LC STN Files: CA, CAPLUS

CM 1

CRN 31645-34-8

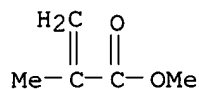
CMF C18 H14 O2



CM 2

CRN 80-62-6

CMF C5 H8 O2



3 REFERENCES IN FILE CA (1967 TO DATE)

3 REFERENCES IN FILE CAPLUS (1967 TO DATE)

L1 ANSWER 2 OF 3 REGISTRY COPYRIGHT 2001 ACS

RN 31645-34-8 REGISTRY

CN 2-Propenoic acid, 9-anthracenylmethyl ester (9CI) (CA INDEX NAME)

OTHER CA INDEX NAMES:

CN 9-Anthracenemethanol, acrylate

CN Acrylic acid, 9-anthrylmethyl ester (7CI, 8CI)

OTHER NAMES:

CN 9-Anthracenylmethyl acrylate

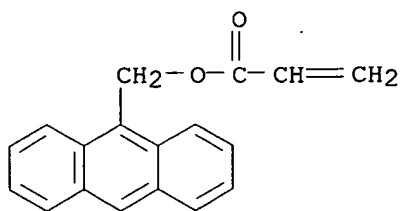
CN 9-Anthrylmethyl acrylate

FS 3D CONCORD

MF C18 H14 O2

CI COM

LC STN Files: BEILSTEIN*, CA, CAOLD, CAPLUS, CASREACT, CHEMCATS, USPATFULL
(*File contains numerically searchable property data)



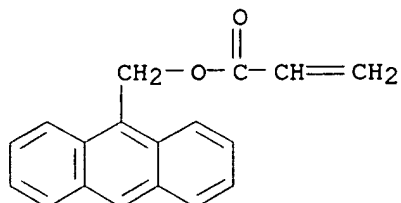
PROPERTY DATA AVAILABLE IN THE 'PROP' FORMAT

13 REFERENCES IN FILE CA (1967 TO DATE)
 13 REFERENCES IN FILE CAPLUS (1967 TO DATE)
 1 REFERENCES IN FILE CAOLD (PRIOR TO 1967)

L1 ANSWER 3 OF 3 REGISTRY COPYRIGHT 2001 ACS
 RN 30175-58-7 REGISTRY
 CN 2-Propenoic acid, 9-anthracenylmethyl ester, homopolymer (9CI) (CA INDEX NAME)
 OTHER CA INDEX NAMES:
 CN Acrylic acid, 9-anthrylmethyl ester, polymers (8CI)
 OTHER NAMES:
 CN **9-Anthrylmethyl acrylate homopolymer**
 MF (C18 H14 O2)x
 CI PMS
 PCT Polyacrylic
 LC STN Files: CA, CAPLUS, IFICDB, IFIPAT, IFIUDB

CM 1

CRN 31645-34-8
 CMF C18 H14 O2



3 REFERENCES IN FILE CA (1967 TO DATE)
 3 REFERENCES IN FILE CAPLUS (1967 TO DATE)

=>